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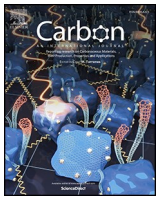

Corrigendum

Corrigendum to "Capillary adhesion governs the friction behavior of electrochemically corroded polycrystalline diamond" [Carbon 205 (2023) 345–352]

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The authors regret that the printed version of the above article contained a number of errors. The captions of Fig. 1 and Fig. 2 missed some important information regarding the image copyright. The correct and final version is as follows:

"Fig. 1. Schematic of electrochemical-atomic force microscopy (EC-AFM) set-up: (a) isometric view and (b) cutaway view. AFM images of pristine (c) MCD and (d) NCD surfaces. (Copied under the terms of the Creative Commons license [30]) (e) Optical image of colloidal probe with a diameter of 15 μm. (f) AFM image of the apex of the microsphere. (A colour version of this figure can be viewed online.)"

and.

"Fig. 2. In-situ AFM imaging with the scanning area of 2 μm × 2 μm illustrating the surface topography evolution of MCD (a) and NCD (b) at various electrochemical corrosion time. Insets show the images of the static water contact angle of MCD and NCD surfaces before and after 2.5 h electrochemical corrosion (c) Surface roughness (RMS) of the measured area in (a) and (b). (Reproduced under the terms of the Creative Commons license [30]) (A colour version of this figure can be viewed online.)"

The authors would like to apologise for any inconvenience caused.

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